Application No. 10/659,190 Reply to Office Action of January 3, 2006

## General to and Listing of the Claims:

Please amend claims 6 and 9 and cancel claim 7, without prejudice, as shown below in the following listing of all claims ever presented. The following listing of claims places all prior versions of the claims.

## 1-5. (Canceled)

6. (Currently Amended) A method of producing a semiconductor device, comprising a step of forming a copper wiring by chemical mechanical polishing and washing with washing liquid for a semiconductor substrate comprising a basic compound and mannitol at least one selected from the group consisting of sugar alcohols and saccharides.

## 7. (Canceled)

- 8. (Original) The method according to claim 6, wherein the basic compound is a quaternary ammonium hydroxide.
- 9. (Currently Amended) The method according to claim 6, wherein the concentration of the mannitol sugar-alcohol is from 0.01 to 5 wt%.
- 10. (Original) The method according to claim 6, wherein the concentration of the basic compound is from 0.05 to 1 wt%.

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